

June 30, 2011

**OBJECT: Patent of “@Hyway”**

Dear all of our valued customers,

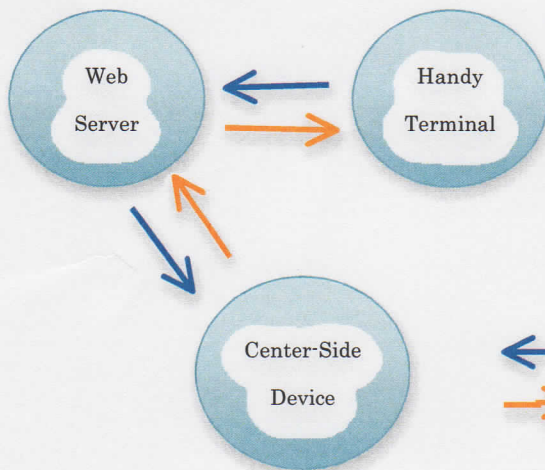
Our product, “HaiSurf2”, and the product of Sino-Japanese Engineering Corp, “@Hyway”, have similarity in the business concept. Therefore, some of you may concern that “HaiSurf2” violates the patent which “@Hyway” has obtained. However, as a result of further investigation conducted by our corporate lawyer and patent attorneys, it is concluded that “HaiSurf2” does not infringe on the patent (Please refer the illustration below).

We apologize for any concern that we may have caused to you. We continue to be committed to providing all of our customers with the highest standard of service in the industry.

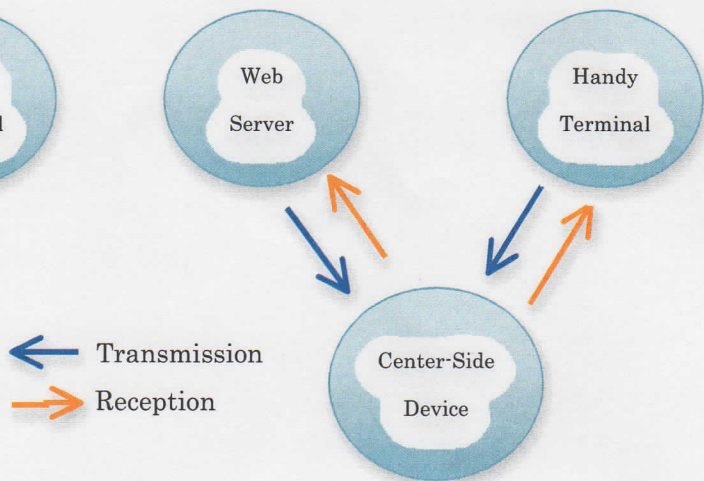
Sincerely,

*Naoki Yamamoto*  
Chief Executive Officer  
Shared System, Inc.

“HaiSurf2”



“@Hyway”



By: *Shinrye Honma*

Attorney  
Nasu Honma Law Offices

By: *[Signature]*

Chief Manager  
Mogami International Patent Offices